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ARTICLE TYPE

Enhanced photodegradation activity of methyl orange over Z-scheme type MoO₃/g-C₃N₄ composite under visible light irradiation

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Novel Z-scheme type MoO₃/g-C₃N₄ composites photocatalysts were prepared with a simple mixing-calcination method, and evaluated for their photodegradation activities of methyl orange (MO). The optimized MoO₃/g-C₃N₄ photocatalyst shows a good activity with a kinetic constant of 0.0177 min⁻¹, 10.4 times higher than that of g-C₃N₄. Controlling various factors (MoO₃/g-C₃N₄ amount, initial MO concentration, and pH value of MO solution) can lead to the enhancement of the photocatalytic activity of the composite. Only MoO₃ and g-C₃N₄ are detected with X-ray diffraction (XRD) and Fourier transform infrared spectroscopy (FT-IR) spectra. N₂ adsorption and UV-vis diffuse reflectance spectroscopy (DRS) results suggest that the addition of MoO₃ slightly affects the specific surface area and the photoabsorption performance. The transmission electron microscopy (TEM) image of MoO₃/g-C₃N₄ indicates a close contact between MoO₃ and g-C₃N₄, which is beneficial to interparticle electron transfer. The high photocatalytic activity of MoO₃/g-C₃N₄ is mainly attributed to the synergetic effect of MoO₃ and g-C₃N₄ in electron-hole pair separation via the charge migration between the two semiconductors. The charge transfer follows direct Z-scheme mechanism, which is proven by the reactive species trapping experiment and the •OH-trapping photoluminescence spectra.

1. Introduction

Organic pollutants are present in the water environment usually as a result of industrial effluents. With the development of industry, the volume of wastewater containing nonbiodegradable pollutants have increased rapidly. Dealing with the pollutants demands the development of new, effective, clean, and safe decontamination technologies. Photocatalysis represents a promising alternative technology for degradation of organic pollutants in water, and hence attracts much attention¹. Titanium oxide (TiO₂) has been used to degrade many organic pollutants in water and air²⁻⁶. It is considered as a promising photocatalyst since it is stable, insoluble, non-toxic, resistant to corrosion and relatively inexpensive. However, TiO₂ photocatalyst is effective only under irradiation of UV light due to its wide band gap. Many strategies, such as metal or nonmetal element doping⁷⁻⁹, dye sensitization¹⁰ and semiconductor coupling¹¹, have been applied to overcome the shortcoming. Cost-effective photocatalysts with high efficiencies under visible light are desired.

Currently, many scientists pay attention on the non-TiO₂ based photocatalyst and developed a lot of novel photocatalysts, such as Bi₂WO₆¹², g-C₃N₄¹³, Ag₃PO₄¹⁴, AgBr¹⁵, etc. Among them, g-C₃N₄ attracted a great deal of interests due to its good photoactivity, moderate band gap, and low cost. In addition, it is considered as a "sustainable" material since pure g-C₃N₄ is a metal-free semiconductor and can be synthesized by the simple

calcination of urea and melamine at 500-600 °C¹⁶⁻¹⁷. Three approaches have been applied to promote its photocatalytic activity in degrading organics more efficiently: increasing the surface area¹⁸⁻¹⁹, doping with metal or nonmetal elements²⁰⁻²¹, coupling with another semiconductor²²⁻²³. The last method was considered as the most feasible one, which has been applied to develop Pt/CdS/PdS composite with the highest quantum efficiency achieved so far²⁴. Since Wang et al. first reported the photocatalytic activity of g-C₃N₄¹³, a variety of g-C₃N₄ based composite photocatalysts have been reported. A number of semiconductors, such as WO₃²⁵, ZnO²⁶, SmVO₄²⁷, Bi₂WO₆²⁸, AgBr²⁹ etc., have been used as a doper to strengthen the photocatalytic activity of g-C₃N₄. The promotion effect was usually explained by three different mechanisms. The first one is sensitization in which electrons generated by visible-light irradiation in g-C₃N₄ migrate to a wider bandgap semiconductor (such as ZnO, TiO₂, YVO₄)^{26,30-31}, while the photogenerated holes stay in the g-C₃N₄. This would facilitate electron-hole separation, suppress charge recombination, and hence improve the photocatalytic activity. The second one is often-associated with heterojunction composite photocatalyst in which both semiconductors can be excited to generate electron-hole pairs²⁷⁻²⁸. The photogenerated electrons from g-C₃N₄ with a higher conduction band could transport to another semiconductor with a lower conduction band. Meanwhile, the photogenerated holes from the semiconductor with a lower valence band transport to the g-C₃N₄ with a higher valence band. The double charge

transfer may also lead to the separation of electrons and holes and enhance the photo-catalytic efficiency. The third one could be called as direct Z-scheme type mechanism. Taking g-C₃N₄/TiO_{2-x}S_x photocatalyst as an example, the photogenerated electrons from the TiO_{2-x}S_x semiconductor with a lower conduction band recombine with photogenerated holes from the g-C₃N₄ with a higher valence band³². By this way, the electrons on g-C₃N₄ and holes on S-TiO₂ are separated efficiently. The g-C₃N₄/TiO_{2-x}S_x composite showed four times higher quantum efficiency than S doped TiO₂ in the photodegradation of acetaldehyde³². Although all the three mechanisms have been widely used by scientists to explain their works, there are still some questions about how to choose the mechanism suitable to a specific research. The band edge potential of semiconductor is generally considered as the criterion which works well in the differentiation of the first two mechanisms. However, it is not enough to distinguish the double-charge-transfer mechanism and direct Z-scheme mechanism. More detailed works need to be done for resolving the issue.

A new Z-scheme type photocatalyst, MoO₃/g-C₃N₄ composite in spite of its similarity to g-C₃N₄ doped MoO₃ composite³³, was developed in this paper. Li et al.³³ think that the g-C₃N₄/MoO₃ composite follows the double-charge-transfer mechanism. However, this research proved that the real mechanism is Z-scheme type mechanism based on the active species trapping experiment. In addition, in comparison to Li's catalyst with 93.0 wt.% MoO₃, a very low content of MoO₃ (1.5wt%) was used in this work, while the latter exhibits excellent photocatalytic activity in dyes photodegradation under visible light irradiation. The high activity and low cost indicates that the MoO₃/g-C₃N₄ is promising photocatalyst.

2. Experimental Section

2.1 Catalysts preparation

(NH₄)₆Mo₇O₂₄·4H₂O (>99.0%), melamine (99.0%), urea (99.0%), tetrabutyl titanate (>99.0%), benzoquinone (>98.0%), KI (>99.0%), isopropanol (>99.7%), coumarin (>99.0%), and ethanol (>99.5%) were purchased and used without further purification. N-doped TiO₂ was prepared by a modified sol-gel method³⁴. Pure MoO₃ was prepared by directly calcining at 500 °C for 4 h. Pure g-C₃N₄ powders were prepared by directly calcining melamine in a muffle furnace. In a typical synthesis run, 6 g of melamine was placed in an alumina crucible with a cover. The crucible was heated to 520 °C for 4 h at a heating rate of 10 °C/min. After cooling to room temperature, yellow g-C₃N₄ was obtained in a powder form.

The MoO₃/g-C₃N₄ composites were prepared according to the following procedure. 0.03 g of MoO₃ and 1.97 g of g-C₃N₄ were mixed and ground in an agate mortar for 20 min. Then, the mixture was calcined at 400 °C for 2h to obtain the 1.5wt.% MoO₃/g-C₃N₄ catalyst. Other MoO₃/g-C₃N₄ catalysts were prepared by a same method except the g-C₃N₄ concentration.

2.2 Photocatalytic reaction

The photocatalytic activities of the synthesized powders were evaluated by degrading methyl orange (MO) under visible-light

irradiation. The light source for photocatalysis was a spherical Xe lamp (350 W). Two optical filters were used to eliminate the UV light and infrared light (800 nm > λ > 420 nm). The power density at the position of reactor is about 16 mW/cm². The volume of initial MO solution is 100 mL. All the powder contents in the MO aqueous solution are 0.10 g/100mL. Prior to irradiation, the mixture was agitated for an hour to ensure adsorption/desorption equilibrium at room temperature. At regular intervals, samples were withdrawn and centrifuged to remove photocatalyst for analysis. The concentration of aqueous MO was determined by measuring its absorbance at the range of 400 nm to 700 nm. The MO degradation was calculated by Lambert–Beer equation. Photoactivity for MO under visible-light irradiation in the absence of the photocatalyst was also evaluated. The photodegradation of other dyes, rhodamine B (RhB) and methylene blue (MB), was also carried out by the similar procedure.

The examination experiment process of reactive species was similar to the photodegradation experiment. A quantity of scavengers was introduced into the MO solution prior to addition of the catalyst. The concentration of scavengers was controlled to be 0.01 mol/L according to the previous studies³⁵⁻³⁶ with the exception of benzoquinone (0.0001 mol/L).

The formation rate of •OH at photo-illuminated sample/water interface was detected by the photoluminescence (PL) technique using coumarin (COU) as a probe molecule. The measurement was carried out in the photocatalytic testing system. In a typical run, 0.2 g of the samples was added to an aqueous solution (100 mL) containing 10 mM COU in a 250 mL beaker. After irradiation for a given time, 8 mL aliquots were sampled and centrifuged for analysis. The •OH formed in the system can react with COU and generate 7-hydroxycoumarin (7HC), the fluorescence intensity of which is directly proportional to the generated •OH³⁷.

2.3 Characterization

Thermogravimetry analysis (TG-DTA; Netzsch STA449) was carried out in a flow of air (10 mL/min) at a heating rate of 10 °C/min. The specific surface areas were measured on Autosorb-1 (Quantachrome Instruments) with Brunauer–Emmett–Teller (BET) method. The XRD characterization of catalysts was carried out on Philips PW3040/60 X-ray diffractometer, using Cu Kα radiation (40 kV/40 mA). The FT-IR spectra of the catalysts were recorded on Nicolet NEXUS670 with a resolution of 4 cm⁻¹. The X-ray photoelectron spectroscopy (XPS) measurements were performed with a Quantum 2000 Scanning ESCA Microprobe instrument using AlKα. The C 1s signal was set to a position of 284.6 eV. The scanning electron microscopy (SEM) pictures were taken on a field emission scanning electron microscope (LEO-1530). The TEM images were collected with a JEM-2010F transmission electron microscope at an accelerating voltage of 200 kV. The DRS spectra of catalysts were recorded on a UV-vis spectrometer (PerkinElmer Lambda900) equipped with an integrating sphere. The PL spectra were collected on FLS-920 spectrometer (Edinburgh Instrument), using a Xe lamp (excitation at 365 nm and 332 nm for photocatalyst and 7HC, respectively) as light source.

Photocurrent was measured on an electrochemical analyzer (CHI660B) in a two-electrode system under zero bias. The

prepared sample and a Pt wire are used as the working electrode and the counter electrode, respectively. A 350 W Xe arc lamp through a UV-cutoff filter ($\lambda > 420$ nm) served as a light source. Na_2SO_4 (0.5 mol/L) aqueous solution was used as the electrolyte. Working electrodes were prepared based on the literature reported²⁷.

3. Results and discussion

3.1 Characterizations of g-C₃N₄, MoO₃ and MoO₃/g-C₃N₄ composites.

Thermo-gravimetric analysis was performed from room temperature to 800 °C under air conditions to determine the real content of MoO₃ in MoO₃/g-C₃N₄ composite. The results are shown in Fig. 1. For clarity, only the TG profiles of pure g-C₃N₄ and three MoO₃/g-C₃N₄ composites are presented. It can be observed that the weight of pure g-C₃N₄ decreased rapidly in the temperature range of 600-750 °C, indicating that the decomposition of g-C₃N₄ occurred in this temperature range. For MoO₃/g-C₃N₄ composite, the weight-loss range shift forwards to 480-570 °C, which suggests that the existence of MoO₃ promotes the combustion of g-C₃N₄, as observed in the SmVO₄/g-C₃N₄ photocatalyst²⁷. The real concentration of MoO₃ can be easily calculated from the residuals after the samples were heated over 600 °C. As shown in Table 1, the real MoO₃ content is slightly larger than the theoretical values. Actually, the difference between the real and theoretical value of g-C₃N₄ is usually large in the reported g-C₃N₄ based photocatalysts^{27,38-39}. The small difference in the MoO₃/g-C₃N₄ might be ascribed to the low preparation temperature (400 °C). Besides the weight loss of g-C₃N₄, another weight loss between 750-800 °C in the MoO₃/g-C₃N₄ composites, could be ascribed to the vaporization of MoO₃. This result is consistent with the phase composition. The BET surface areas of MoO₃/g-C₃N₄ composites are also shown in Table 1. Pure MoO₃ exhibits much lower surface area than pure

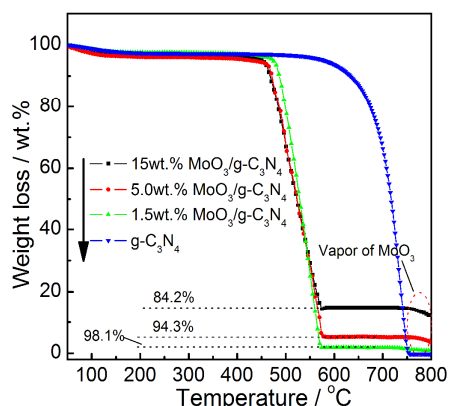


Fig. 1 TG profiles of MoO₃/g-C₃N₄ composites.

Table 1 Specific surface area and the real MoO₃ concentrations of MoO₃/g-C₃N₄ composites.

| Catalysts | S/m ² ·g ⁻¹ | MoO ₃ content/ wt.% |
|------------------------------------------------------------|-----------------------------------|--------------------------------|
| g-C ₃ N ₄ | 13 | 0 |
| MoO ₃ | 1.7 | 100 |
| 1.0 wt.% MoO ₃ /g-C ₃ N ₄ | 14.7 | 1.2 |
| 1.5wt.% MoO ₃ /g-C ₃ N ₄ | 14.4 | 1.9 |
| 2.0wt.% MoO ₃ /g-C ₃ N ₄ | 11.6 | 2.4 |
| 5.0wt.% MoO ₃ /g-C ₃ N ₄ | 7.1 | 5.7 |
| 15wt.% MoO ₃ /g-C ₃ N ₄ | 6.9 | 15.8 |

g-C₃N₄. However, the addition of a small amount of MoO₃ to g-C₃N₄ led to the increase in the BET value of photocatalyst, which might be due to the interaction between the two semiconductors. With the further increase of the MoO₃ concentration, the BET value decreased from 14.7 m²/g to 6.9 m²/g. 15 wt.% MoO₃/g-C₃N₄ sample presents the lowest specific surface area.

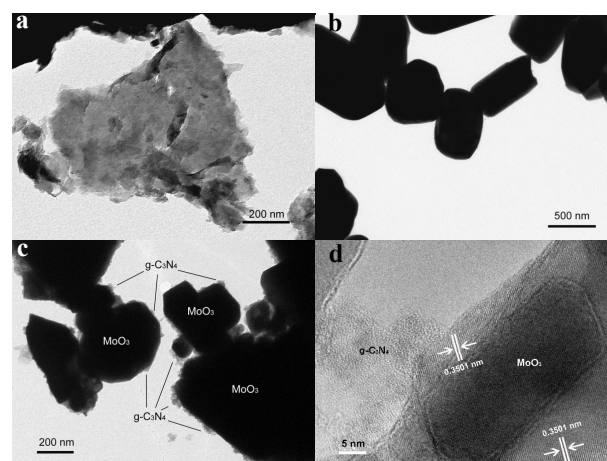


Fig. 2 TEM images of g-C₃N₄ (a), MoO₃ (b), and 1.5 wt.% MoO₃/g-C₃N₄ (c,d) photocatalysts.

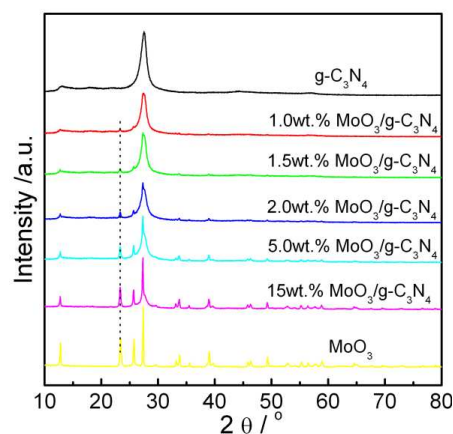


Fig. 3 XRD patterns of MoO₃/g-C₃N₄ composites with different MoO₃ concentration.

Fig. 2 shows the TEM pictures of g-C₃N₄, MoO₃, and 1.5 wt.% MoO₃/g-C₃N₄ composite. As shown in Fig. 2a, the morphology of pure g-C₃N₄ seems to be smooth, which is also confirmed by SEM observation (Fig. S2a). The layer structure might be the origin of the special morphology of g-C₃N₄. Different from g-C₃N₄, MoO₃ sample had a particle size of 200-600 nm, and a grain-like morphology with polygonal grain shapes (Fig. 2b and S2b). For the MoO₃/g-C₃N₄ composite, several MoO₃ particles were sparsely observed on the g-C₃N₄ surface (Fig. S2c), and almost all particles were in direct contact with the g-C₃N₄. The TEM image of MoO₃/g-C₃N₄ gives detailed information on the contact of the two semiconductors. As can be seen in Fig. 2c, the big black particles could be assigned to MoO₃ grain, while g-C₃N₄ closely adhered to the surface of MoO₃. The close contact can be observed more clearly in the high-resolution TEM image. As shown in Fig. 2d, two different phases were observed. The dark and big phase which exhibits fringes with an interplanar spacing of about 0.3501 nm can be indexed into the

(040) plane of MoO_3 , whereas another phase without fringes can be assigned to $\text{g-C}_3\text{N}_4$. Additionally, because the $\text{MoO}_3/\text{g-C}_3\text{N}_4$ hybrids were ultrasonicated for 20 min before TEM analysis, the result in Fig. 2c and 2d indicates that the interaction between the MoO_3 particles and $\text{g-C}_3\text{N}_4$ is very strong, which is beneficial to the formation of hetero-junction of MoO_3 and $\text{g-C}_3\text{N}_4$.

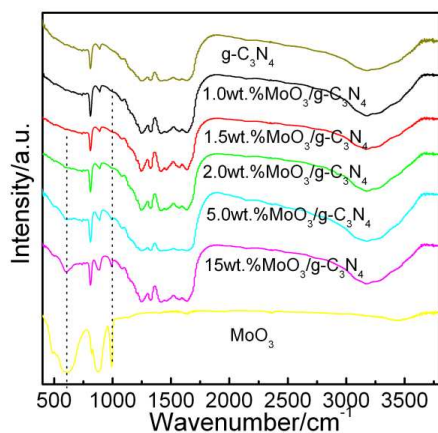


Fig. 4 FT-IR spectra of $\text{MoO}_3/\text{g-C}_3\text{N}_4$ composites with different MoO_3 concentration.

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The structure of $\text{MoO}_3/\text{g-C}_3\text{N}_4$ composites was characterized by XRD and FT-IR. Fig. 3 shows the XRD patterns of MoO_3 , $\text{g-C}_3\text{N}_4$, and $\text{MoO}_3/\text{g-C}_3\text{N}_4$ composites with different MoO_3 concentration. Pure $\text{g-C}_3\text{N}_4$ shows two broad peaks at $2\theta = 13.0^\circ$ and 27.4° , which are the (001) and (002) diffraction planes of the graphite-like carbon nitride, respectively¹³. Pure MoO_3 is in its orthorhombic phase (JCPDF 35-0609) and exhibits several strong diffraction peaks at $2\theta = 12.8^\circ, 23.4^\circ, 25.7^\circ, 27.3^\circ, 33.8^\circ, 39.0^\circ$ ⁴⁰. In the $\text{MoO}_3/\text{g-C}_3\text{N}_4$ composite, although the content of MoO_3 is very low, MoO_3 phase could still be observed due to its strong XRD signal. As MoO_3 concentration increases from 1.0 wt% to 15 wt.%, the diffraction peaks of MoO_3 are gradually intensified, whereas the peaks of $\text{g-C}_3\text{N}_4$ are weakened. This result accords well with that of TG experiment. With the exception of MoO_3 and $\text{g-C}_3\text{N}_4$, no other phase was observed. The same result was also obtained in the FT-IR experiment. As shown in Fig. 4, pure $\text{g-C}_3\text{N}_4$ shows strong IR signal in the range of $1200\text{--}1600\text{ cm}^{-1}$, which could be assigned to the C=N and aromatic C-N stretching vibration modes⁴¹. In addition, the signal of out-of plane bending modes of C-N heterocycle was also observed at 808 cm^{-1} ⁴¹. For MoO_3 , only three strong IR peaks were observed. The peak at 996 cm^{-1} could be assigned to the Mo=O stretching mode, while the peaks at 562 cm^{-1} and 859 cm^{-1} originate from the stretching mode of oxygen linked with three metal atoms and in the Mo-O-Mo units, respectively⁴². In the case of $\text{MoO}_3/\text{g-C}_3\text{N}_4$ composite, the position of these characteristic peaks is as same as that of pure phase. The peak intensity of MoO_3 increases with the MoO_3 content, which is consistent with the results obtained with XRD.

XPS measurements were performed to explicate the valence states of various species. Fig. 5 shows the C1s high resolution XPS spectra of MoO_3 , $\text{g-C}_3\text{N}_4$ and several $\text{MoO}_3/\text{g-C}_3\text{N}_4$ composites. Pure $\text{g-C}_3\text{N}_4$ has two C1s peak located at 284.6 eV and 288.0 eV, which could be attributed to C-C coordination of carbon-containing contaminations and N-C-N coordination in graphitic carbon nitride, respectively⁴¹. For MoO_3 , only the contaminated carbon was observed. Hence, the C1s peak at 288.0 eV could be used to verify the existence of $\text{g-C}_3\text{N}_4$ in the $\text{MoO}_3/\text{g-C}_3\text{N}_4$ photocatalyst. Generally, the N1s peak can also be

the standard. The peak at 398.5 eV and 400.6 eV could be separately assigned to the nitrogen atoms in C-N-C and $-\text{NH}_x$ groups⁴¹. No shift was observed in the C1s or N1s peak after the addition of MoO_3 except a slight red shift of N1s in 15wt.% $\text{MoO}_3/\text{g-C}_3\text{N}_4$ sample. Li et al. observed the shift of N1s peak in 7 wt.% $\text{g-C}_3\text{N}_4/\text{MoO}_3$ composite and attributed it to the interaction between Mo and N atoms³³. However, it should be noted that the binding energy (BE) of $\text{Mo } 3p_{3/2}$ is very close to that of N1s. We think the contribution of $\text{Mo } 3p_{3/2}$ might be the reason of the N1s peak shift. Fig. 5c shows the high resolution XPS peak of O1s. MoO_3 has a strong O1s peak at 530.8 eV which could be attributed to the O^{2-} in molybdenum oxide⁴³, while $\text{g-C}_3\text{N}_4$ has a small O1s peak originated from adsorbed H_2O ⁴¹. The O1s peak of $\text{MoO}_3/\text{g-C}_3\text{N}_4$ could be seen as the overlap of the two oxygen species. With the increase of the MoO_3 content, the position of O1s shifts to low binding energy end. The high-resolution XPS spectrum of Mo 3d exhibits the Mo ($3d_{5/2}$, $3d_{3/2}$) doublet at 232.9 eV and 236.0 eV (Fig. 5d), the typical binding energies of Mo^{6+} ⁴⁴⁻⁴⁵. In the case of $\text{MoO}_3/\text{g-C}_3\text{N}_4$, the BEs of $\text{Mo } 3d_{5/2}$ and $\text{Mo } 3d_{3/2}$ are 232.3 and 235.4 eV, respectively. Earlier studies show that the Mo $3d_{5/2}$ BE of MoO_2 is 229.6 eV, and the BE of $\text{Mo}^{3+} 3d_{5/2}$ is 232.0 eV⁴⁴⁻⁴⁵. So, both Mo^{5+} and Mo^{6+} exist in the surface of $\text{MoO}_3/\text{g-C}_3\text{N}_4$ samples, although the XRD experiment indicates that molybdenum exists in the forms of crystalline MoO_3 . The Mo^{5+} might originate from the catalytic oxidation of $\text{g-C}_3\text{N}_4$ by MoO_3 during the preparation of $\text{MoO}_3/\text{g-C}_3\text{N}_4$, which has been proven by the TG-DTA experiment (see Fig. S1). Some Mo^{6+} ions were reduced to Mo^{5+} during the heating process. The reaction between $\text{g-C}_3\text{N}_4$ and MoO_3 consumed some $\text{g-C}_3\text{N}_4$. Meanwhile, it promotes the interaction between the two semiconductors, which benefits the decrease in interface energy and the charge transfer between them. In addition, it could be observed that the change in MoO_3 concentration did not affect the BE of $\text{Mo } 3d_{5/2}$, which suggests that the surface Mo^{5+} concentration is stable in the $\text{MoO}_3/\text{g-C}_3\text{N}_4$ composites. The surface phase composition of the 1.5 wt% $\text{MoO}_3/\text{g-C}_3\text{N}_4$ sample was obtained based on the XPS spectra. The MoO_3 concentration of the sample (Table S1) is 1.0 mol%, which is close to 1.2 mol% (obtained with TG). This result

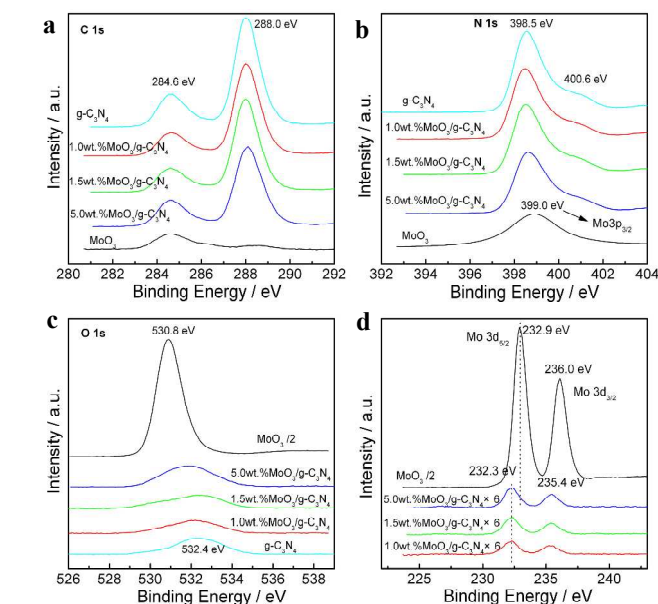


Fig. 5 XPS spectra of MoO_3 , $\text{g-C}_3\text{N}_4$ and $\text{MoO}_3/\text{g-C}_3\text{N}_4$ composites, (a) C1s; (b) N1s; (c) O1s; (d) Mo3d.

indicates well dispersion of MoO₃ in composite, benefiting the formation of heterojunction structure between MoO₃ and g-C₃N₄. The valence band (VB) XPS spectra of g-C₃N₄ and MoO₃ are shown in Fig. 6. The position of the valence band edges of g-C₃N₄ and MoO₃ are 1.53 eV and 3.20 eV, respectively.

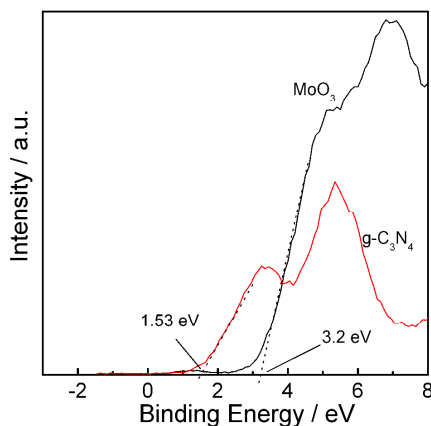


Fig. 6 Valence band XPS of MoO₃ and g-C₃N₄

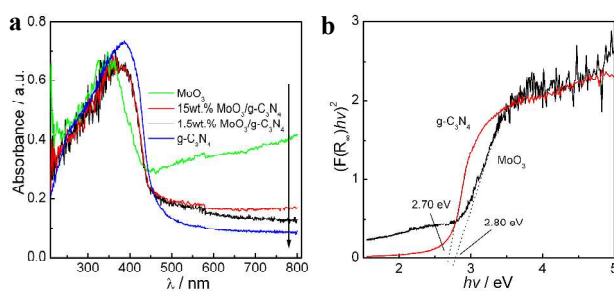


Fig. 7 UV-vis spectra of MoO₃/g-C₃N₄ (a) composites and the estimated band gaps of g-C₃N₄ and MoO₃ (b).

Fig. 7 shows the UV-vis DRS spectra of MoO₃/g-C₃N₄ composites. Only the spectra of 1.5wt.% MoO₃/g-C₃N₄ and 15wt.% MoO₃/g-C₃N₄ photocatalysts are presented. For all samples, the optical absorption edge was estimated to be at around 470 nm. This is consistent with their pale yellow color. Pure g-C₃N₄ has the best photoabsorption performance. The band gap was estimated to be 2.70 eV based on the K-M equation⁴⁶. The band gap of MoO₃ is 2.80 eV. Both accord well with the reported values^{13,45}. The optical properties of MoO₃/g-C₃N₄ fall in between those of MoO₃ and g-C₃N₄. However, due to the low concentration of MoO₃ and the similar band gap of the two semiconductors, the composites with different MoO₃ contents exhibit nearly same photoabsorption performance

3.2 Photocatalytic activities of g-C₃N₄, MoO₃, and MoO₃/g-C₃N₄

To evaluate the photocatalytic activity of as-prepared MoO₃/g-C₃N₄ composites, the degradation of MO was carried out. Fig. 8a displays the changes of the MO concentration versus the reaction time over MoO₃/g-C₃N₄ photocatalysts prepared with different MoO₃ concentrations. The blank test shows that MO is stable under visible light irradiation, indicating that the photolysis of MO is negligible. MoO₃ barely shows activity for MO photodegradation, while g-C₃N₄ demonstrates good photocatalytic activity with a degradation rate of 0.0017 min⁻¹

(Fig. 8b). The rate was estimated based on

$$\ln(C_0/C_t) = kt \quad (E1)$$

where C_0 is the equilibrium concentration of MO after 60 min dark adsorption, C_t is the MO concentration remaining in the solution at irradiation time t (min), and k is the observed rate constant²⁸⁻²⁹. The addition of MoO₃ to g-C₃N₄ promotes the degradation of MO effectively. With the increase in MoO₃ concentration, the photocatalytic activity of MoO₃/g-C₃N₄ increases and then decreases. 1.5wt.% MoO₃/g-C₃N₄ exhibits the highest photocatalytic efficiency. The k value is 0.0177 min⁻¹ which is 10.4 times higher than that of pure g-C₃N₄. Obviously, the coupling of MoO₃ and g-C₃N₄ creates an excellent composite photocatalyst. Considering that the MoO₃/g-C₃N₄ composites have similar specific surface area with g-C₃N₄, the enhanced photoactivity may be ascribed to the improvement in charge transmission between the semiconductors g-C₃N₄ and MoO₃ prolonged the lifetime of charge carriers. Moreover, the photoactivity of the coupled semiconductors was also affected by the surface contact between particles. 1.5wt.% MoO₃/g-C₃N₄ might have the highest contact interfaces between MoO₃ and g-C₃N₄, and thus the highest photocatalytic efficiency.

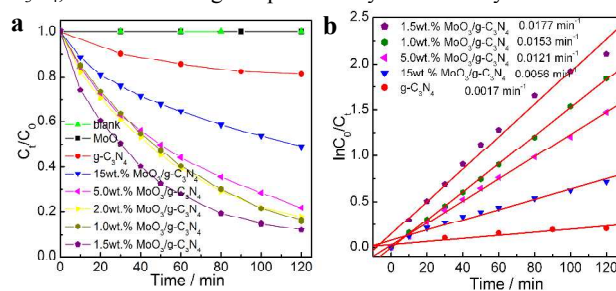


Fig. 8 Photocatalytic activities of MoO₃/g-C₃N₄ composites on photodegradation of MO under visible-light irradiation (a) and the corresponding kinetic studies (b). (Catalyst's content: 1.0g/L; MO content: 20 ppm).

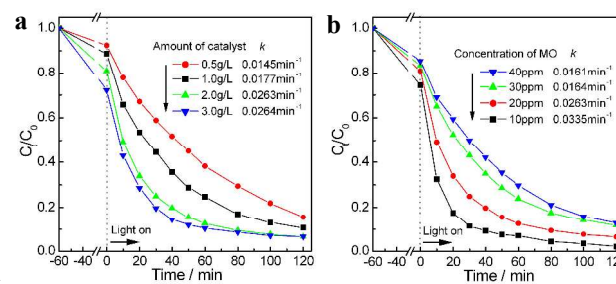


Fig. 9 Effect of catalyst content (a) and initial dye concentration (b) on the degradation of MO.

Reaction conditions also have great effects on the photocatalytic reaction. The optimal reaction condition could accelerate the photocatalytic oxidation of dye. Therefore, in order to degrade MO more efficiently, the 1.5 wt.% MoO₃/g-C₃N₄ sample was employed for the following investigations. It can be seen from Fig. 9a that the degradation rate of MO increased from 0.0145 min⁻¹ to 0.0210 min⁻¹ with catalyst amount, and then decreased slightly. Higher catalyst amount means higher availability of total surface area and active sites of the catalyst, and thus better adsorption of MO and degradation rate. However, when the catalyst is overdosed, the reductions in light penetration

and light scattering would result in a reduction of degradation rate. An optimal amount (2.0 g/L) was chosen for the further study. Fig. 9b shows the effect of the initial concentration of MO on the photocatalytic degradation of MO over 1.5 wt.% MoO₃/g-C₃N₄ composite. The increase in MO concentration reduces the degradation efficiency, which might be due to the light attenuation in MO solution or the visible light screening effect of the dye. The higher the MO concentration is, the fewer the light could pass through the MO solution and reach the photocatalyst, and lead to lower photoactivity.

The influence of the pH on the photocatalytic degradation of MO was also investigated and the results are shown in Fig. 10a. When the pH value was lower than 9, pH had little effect on the photocatalytic oxidation of MO. The 1.5 wt.% MoO₃/g-C₃N₄ photocatalyst exhibited good photoactivity in both neutral and acid solution. However, when pH was higher than 9, the photocatalytic activity decreased considerably. The loss of MoO₃ might result in the decrease in photoactivity, which was also observed in cyclic experiments. As shown in Fig. 10b, the degradation efficiency of 1.5 wt.% MoO₃/g-C₃N₄ composite decreased gradually with the increase in the number of cyclic test. In the fourth run, only 55 % of the initial activity was obtained. According to the results of XRD experiments, the disappearance of MoO₃ phase might lead to the inactivation of the photocatalyst (Fig. S2). Unlike WO₃, MoO₃ has very low solubility in water (4.9 g/L, 28 °C). Although the strong interaction between g-C₃N₄ and MoO₃ might slow down the dissolution process, the inactivation of the MoO₃/g-C₃N₄ is observed. It should be noted that the inactivation of MoO₃-containing photocatalyst has not been reported before. All researchers claimed that the synthesized MoO₃-containing photocatalyst is stable and can be recycled with water purification^{32,33,47-48}. The observation might result from the high concentration of MoO₃ in those photocatalysts. MoO₃ dissolution did not affect photocatalytic activity during the several cyclic tests. However, it is no doubt that the inactivation of MoO₃-containing photocatalyst during water purification is unavoidable due to the solubility of MoO₃. The MoO₃-containing composites are more suitable for air purification such as the photodegradation of acetone with SO₄²⁻/MoO₃/MgF₂ composite⁴¹.

Fig. 11a shows the photocatalytic activity of MO, MB, and RhB in the presence of 1.5wt.%MoO₃/g-C₃N₄ composite. It can be seen that the MB and RhB dyes can also be photodegraded efficiently over the MoO₃/g-C₃N₄ photocatalyst besides MO. Indeed, many photocatalysts could only degrade one type of dye. For example, it was reported that CaBi₆O₁₀/Bi₂O₃ photocatalyst is only effective in RhB photodegradation³⁴. Yan et al. found that pure g-C₃N₄ exhibited much higher photocatalytic activity in RhB degradation than that in MO degradation⁴⁹. The result in Fig. 11a indicates the general applicability of the synthesized MoO₃/g-C₃N₄ photocatalyst since RhB and MO are two different type of dyes. Fig. 11b displays the photocatalytic activities of different photocatalysts in photodegradation of MO. Actually, the g-C₃N₄/MoO₃ and WO₃/g-C₃N₄ composite photocatalysts were also prepared based on the reported literatures^{25,33}. However, the synthesized photocatalysts display different photocatalytic behavior from the literatures, which might be due to the inconsistency in preparation techniques and experimental conditions. Hence, in order to eliminate their effects, only the N-TiO₂³⁴, DyVO₄/g-C₃N₄³⁸, and YVO₄/g-C₃N₄³¹ photocatalysts which we have previously reported were chosen as the reference photocatalysts. The result shown in Fig. 11b demonstrated the superiority of MoO₃/g-C₃N₄ composite. The MoO₃/g-C₃N₄ photocatalyst had better performance on photocatalytic oxidation of MO than the other g-C₃N₄ based photocatalysts.

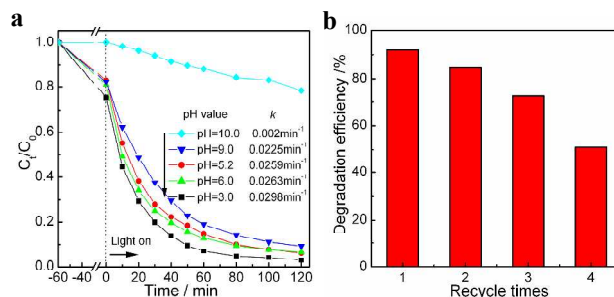


Fig. 10 Effect of the pH value of MO solution on the degradation of MO (a) and the cycling run of 1.5wt.% MoO₃/g-C₃N₄ (b). (content of catalyst: 2.0g/L; content of MO: 20 ppm).

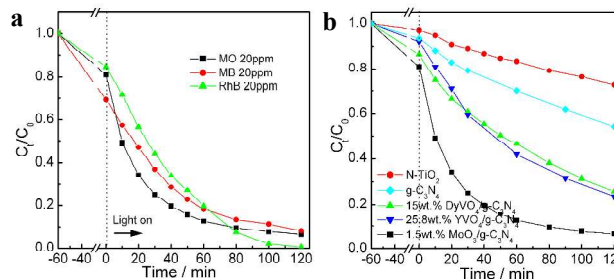


Fig. 11 The photodegradation of different organics over 1.5wt.%MoO₃/g-C₃N₄ sample (a) and the photodegradation of MO over different photocatalysts (b). (Content of catalyst: 2.0g/L; pH=6.0).

Therefore, the synthesized MoO₃/g-C₃N₄ composite is an excellent photocatalyst for the photodegradation of MO, RhB, and MB. The addition of a small amount of MoO₃ could greatly promote the photocatalytic activity of g-C₃N₄. The highest photocatalytic activity could be obtained by optimizing the influencing factors (MoO₃ concentration, catalyst amount, initial MO concentration, pH of MO solution). However, MoO₃/g-C₃N₄ composite is not stable in water. In order to make it applicable for water purification, the modification should be done, which includes coating the exposed MoO₃ surface with a nanocarbon layer to prevent the dissolution of MoO₃.

3.3 Possible mechanism of enhanced photocatalytic activity of MoO₃/g-C₃N₄ composite

Although the surface area of a photocatalyst has been considered as an important factor in determining the photocatalytic activity, the separation efficiency of electron-hole pairs of the composite photocatalyst including MoO₃/g-C₃N₄ used in this research is always the key factor. The excellent photocatalytic activity is associated with the enhanced separation efficiency resulting from the addition of MoO₃. XPS experiment shows that some Mo⁵⁺ species formed on the surface of the composite might contribute to the separation of electron-hole pairs because Mo⁵⁺ has been reported to be the low trap of hole^{7,45}. However, due to the inconsistency of surface Mo⁵⁺ content and photoactivity, the coupling effect between MoO₃ and g-C₃N₄ should be the main reason, suppressing the recombination of electron-hole pairs, and subsequently improving the photocatalytic efficiency. The PL experiment was carried out to confirm the assumption. Fig. 12 shows the PL spectra of pure g-C₃N₄, 1.5 wt.% MoO₃/g-C₃N₄ composite, and 1.9wt.% MoO₃/g-C₃N₄ mixture. The mixture containing the same amount of MoO₃ as the 1.5 wt.% MoO₃/g-C₃N₄ sample was prepared as a reference catalyst. G-C₃N₄ has a

strong PL emission at about 460 nm, an indication of rapid recombination of electrons and holes⁵⁰. The other two samples have a PL peak at the same position. The peak intensities of three materials are in the order of g-C₃N₄ > 1.9 wt.% MoO₃/g-C₃N₄ mixture > 1.5 wt.% MoO₃/g-C₃N₄ composite. In general, the surface energies of MoO₃ and g-C₃N₄ in the mixture should be high due to the lack of calcination, which retards the interparticle electron transfer. Hence, the weak PL intensity of 1.9 wt.% MoO₃/g-C₃N₄ mixture could be mainly ascribed to the decrease in g-C₃N₄ concentration. The fact that PL peak of the 1.5 wt.% MoO₃/g-C₃N₄ composite is weaker than that of the physical mixture verifies the existence of the charge transfer between MoO₃ and g-C₃N₄ particles.

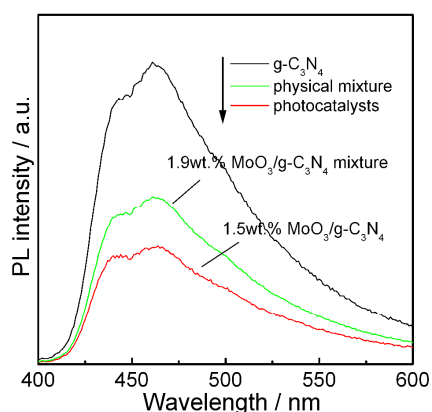


Fig. 12 Photoluminescence spectra of pure g-C₃N₄, 1.5 wt.% MoO₃/g-C₃N₄ composite, and 1.9 wt.% MoO₃/g-C₃N₄ physical mixture.

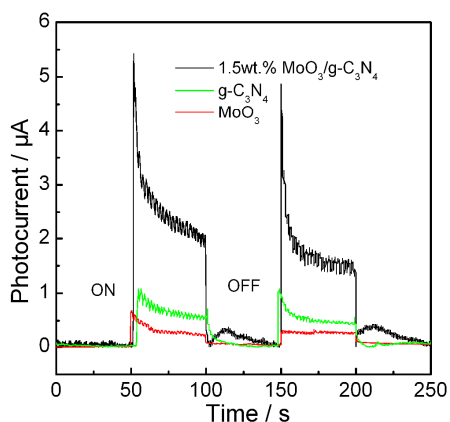


Fig. 13 Transient photocurrent responses for g-C₃N₄ and 1.5 wt.% MoO₃/g-C₃N₄ photocatalysts.

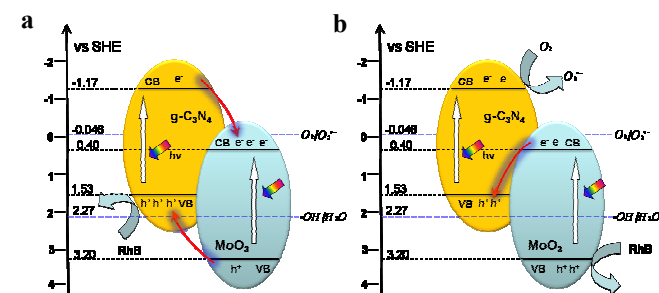


Fig. 14 Possible schemes for electron-hole separation and transport at the visible-light-driven MoO₃/g-C₃N₄ composite interface: (a) double charge transfer mechanism, (b) Z-Scheme mechanism.

The PT experiments were also carried out to reveal dynamics of the charge transfer between the interfacial surface of MoO₃ and g-C₃N₄ semiconductors. As shown from Fig. 13, the photocurrent of 1.5 wt.% MoO₃/g-C₃N₄ is much higher than that of g-C₃N₄ or MoO₃, thus holds stronger ability in generating and transferring the photoexcited charge carrier under visible light irradiation^{51,52}. The results in Fig. 13 are well in agreement with those from the PL experiments.

Therefore, it is obvious that the efficient charge separation is the origin of the high photoactivity of MoO₃/g-C₃N₄. However, the associated mechanism is unclear. Based on

$$E_{cb} = E_g - E_{vb} \quad (E2)$$

and the results of VB XPS and DRS, the band edge potentials of MoO₃ and g-C₃N₄ could be determined. The sensitization mechanism should be excluded since both MoO₃ and g-C₃N₄ have visible light absorption ability. However, the final determination of the working mechanism of the MoO₃/g-C₃N₄ photocatalyst is still difficult because the band potentials of MoO₃ and g-C₃N₄ meet the requirements of both mechanisms (Fig. 14). Li et al. reported that g-C₃N₄/MoO₃ composite follows the double charge transfer mechanism (Fig. 14a)³³. This mechanism was also thought to work in another similar photocatalyst, WO₃/g-C₃N₄ composite^{25,53}. But these authors did not consider the possibility of Z-scheme type mechanism. Meanwhile, some studies showed that the photogenerated electrons migrate by the Z-scheme route in the MoO₃-containing composite photocatalysts (MoO₃/TiO_{2-x}S_x³², Pt/MoO₃/TiO₂⁵⁴, MoO₃/TiO₂⁵⁵). The theory is based on the assumption that the photocatalytic efficiency of the Z-scheme photocatalysis system is limited by the semiconductor with a wider band gap⁵⁶. However, due to the similarity band gaps of MoO₃ and g-C₃N₄, a new method is needed to determine the function mechanism of MoO₃/g-C₃N₄.

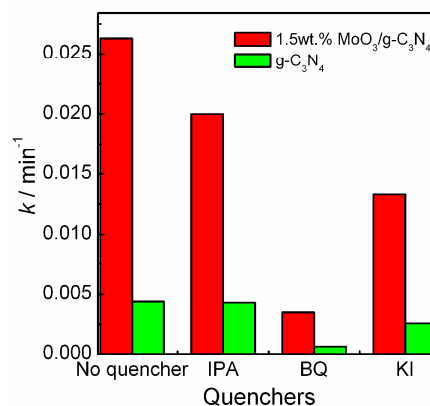


Fig. 15 Kinetic constants of g-C₃N₄ and 1.5 wt.% MoO₃/g-C₃N₄ photocatalyst with different quenchers.

The activity of a photocatalyst originates from the redox ability of electrons and holes¹⁻². The band potentials of a semiconductor greatly affect the photocatalytic reaction. Actually, band potential difference was considered as an important reason of the higher photoactivities of BiOCl and Zn₂GeO₄ than that of P25⁵⁷⁻⁵⁸. However, for composite photocatalysts, the positive effect of charge separation is great enough to control the photocatalytic reaction. The effect of the change in redox ability resulting from the charge migration is usually neglected. Migration does influence the process of the photocatalytic oxidation of organics. For example, although the photocatalytic activity of g-C₃N₄ was greatly improved due to the addition of GdVO₄, the •OH concentration in the presence of

GdVO₄/g-C₃N₄ composite is lower than that of pure g-C₃N₄ and GdVO₄⁵⁹. This change in the content of reactive species could be attributed to the decrease in redox potentials of electron and holes. Hence, in the case of MoO₃/g-C₃N₄ composite, the change in redox ability can affect the reactive species. If the MoO₃/g-C₃N₄ photocatalyst follows the same mechanism as GdVO₄/g-C₃N₄ composite (double charge transfer mechanism, Fig. 14 a), the decrease in •OH concentration would be observed over MoO₃/g-C₃N₄ composite. In addition, due to the conduction band potential of MoO₃ is lower than the standard reduction potential of •O₂⁻/O₂, the electron transfer from the CB of g-C₃N₄ to that of MoO₃ would lead to the significant decrease in •O₂⁻ concentration. It would be impossible that the MoO₃/g-C₃N₄ composite and pure g-C₃N₄ have the same dominant reactive species •O₂⁻. On the contrary, if the MoO₃/g-C₃N₄ follows the Z-scheme type mechanism, the opposite result would be obtained.

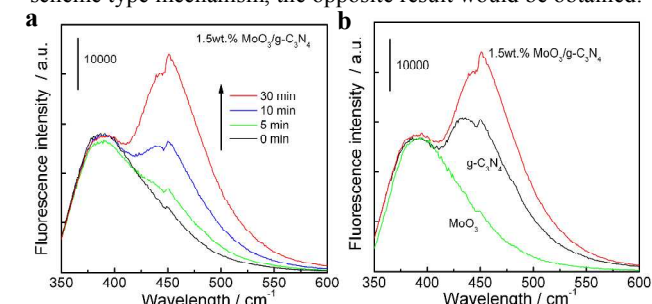


Fig. 16 •OH-trapping photoluminescence spectra of photocatalyst under visible-light irradiation in a solution of COU at room temperature (a) 1.5 wt.% MoO₃/g-C₃N₄. (b) MoO₃, g-C₃N₄, and 1.5 wt.% MoO₃/g-C₃N₄ samples under light irradiation for 30 min.

Fig. 15 shows the kinetic constants of g-C₃N₄ and 1.5 wt.% MoO₃/g-C₃N₄ photocatalyst in the presence of different quenchers. The addition of benzoquinone (BQ, •O₂⁻ scavenger) greatly decreased the photocatalytic activity of g-C₃N₄, indicating that •O₂⁻ is the dominant active species^{35,36}, which is consistent with the Ji's work⁶⁰. A small decrease in *k* was also observed after the addition of KI (KI, •OH and h⁺ scavenger)^{35,36}, whereas isopropanol (IPA, a quencher of •OH) has nearly no effect on the degradation of MO in the presence of g-C₃N₄ catalyst^{35,36}. For the MoO₃/g-C₃N₄ composite, similar results were obtained. The active trapping experiments verified that •O₂⁻ and h⁺ are the reactive species during the photocatalytic oxidation of MO. Thus, MoO₃/g-C₃N₄ composite photocatalyst follows the direct Z-scheme type mechanism. Besides, it could be noted that the isopropanol scavenger displayed a stronger effect on the photoactivity of MoO₃/g-C₃N₄ than that of g-C₃N₄. This phenomenon suggests the increase in •OH concentration in the MoO₃/g-C₃N₄ composite, which is in a good agreement with the expectation of the Z-scheme mechanism.

The increased •OH concentration was verified via the experiments with the trapping of hydroxyl radicals (•OH) by COU. Fig. 16a displays the •OH-trapping photoluminescence spectra of 1.5 wt.% MoO₃/g-C₃N₄ composite under visible-light irradiation. PL emission peak at approximately 456 nm was observed and gradually increased with prolonged irradiation time, which indicates that the •OH was photogenerated³⁷. The PL spectra of MoO₃, g-C₃N₄ and 1.5 wt.% MoO₃/g-C₃N₄ samples under visible light irradiation for 30 min are shown in Fig. 16b. The 1.5 wt.% MoO₃/g-C₃N₄ sample has the strongest PL peak, indicating that •OH concentration was higher than that of pure g-C₃N₄. Obviously, due to the high concentrations of the electron on the CB of g-C₃N₄ and holes on the VB of MoO₃, and thus ease in the generation of •OH species. The data in Fig. 15 and 16

clearly verifies that Z-scheme type mechanism is applicable to the MoO₃/g-C₃N₄ composite photocatalyst.

4. Conclusion

The prepared MoO₃/g-C₃N₄ powders exhibited excellent performance in the degradation of MO, RhB and MB, and displayed much higher photocatalytic activity than single g-C₃N₄ or MoO₃ under visible-light irradiation (>420 nm). The synergic effect of g-C₃N₄ and MoO₃ was considered as the origin of the high activity of MoO₃/g-C₃N₄ composite. However, due to the very low solubility of MoO₃, the deactivation of the photocatalyst in water is unavoidable. The photocatalyst containing MoO₃ might be more suitable for the air purification. In addition, the reactive species trapping experiment and the coumarin photoluminescence probing technique were used for verification of the Z-scheme mechanism of MoO₃/g-C₃N₄ composite. The method employed in this research could help researchers study the photocatalytic mechanism of new composite photocatalyst.

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† Electronic Supplementary Information (ESI) available: TG-DTA profiles of pure g-C₃N₄ and 1.5wt.% MoO₃/g-C₃N₄ composite (Fig. S1), SEM pictures of pure g-C₃N₄, MoO₃, and 1.5wt.% MoO₃/g-C₃N₄ composite (Fig. S2). XRD patterns of 1.5wt.% MoO₃/g-C₃N₄ before and after reaction (Fig. S3). The elemental concentration in 1.5 wt% MoO₃/g-C₃N₄ photocatalyst (Table S1). See DOI: 10.1039/b000000x/

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